

JOURNAL OF PLASMA AND FUSION RESEARCH

The Journal of the Japan Society of Plasma Science and Nuclear Fusion Research

Vol. 85, No.12, December 2009

Special Topic Article

Plasma Technology for Next Generation Crystalline Silicon Solar Cells

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The soft x-ray image of high-beta plasma confined in the magnetospheric device RT-1. (solid line) Superconducting magnet, (dotted line) x-ray CCD camera scope, and (chain lines) ECR layers of (1) 2.45 and (2) 8.2 GHz microwaves. When the magnet is supported, primary loss channel of hot electrons is coil support structure. Levitating the magnet, the plasma pressure is drastically increased; the local beta exceeds 40% and the energy confinement time is longer than 0.1 s. (Haruhiko SAITOH *et al.*, Plasma and Fusion Research Vol.4, 050 (2009) <http://www.jspf.or.jp/PFR/>)

Published Monthly by

The Japan Society of Plasma Science and Nuclear Fusion Research

3-1-1, Uchiyama, Chikusa-ku, Nagoya 464-0075, Japan

Tel 052-735-3185, Fax 052-735-3485, E-mail: plasma@jsof.or.jp, URL: <http://www.jspf.or.jp/>